



KIWO Product News

PRODUCT GROUPS:

Direct Emulsions

- Diazo
- Diazo-Photopolymer
- SBQ

Capillary Films

- Diazo
- Diazo-Photopolymer

Automatic Coating Machines

- KIWOMAT Basic
- KIWOMAT Pro
- KIWOMAT Simplex

Screen Cleaning Products

- Press Washes
- Ink Degradents
- Stencil Removers
- Haze Removers
- Mesh Preparations
- Brushes

Frame Adhesives

Screen Printable Pressure Sensitive Adhesives

- UV Curable
- Solvent Based
- Water Based

Specialty Adhesives

- Temporary Tattoo
- Pallet
- Flocking
- Blanket
- Heat Activated

Computer-To-Screen (CTS) Systems

- Direct UV Exposure
- Wax Ink Jet

Evaluation & Quality Control Tools

- Exposure Calculator
- Thickness Gauge
- Rz Meter
- Instructional Video CD

KIWO's 2-Step **Water Reducible Reclamation (WRR) System** **DUAL STRIP + KIWOCLEAN Concentrated Ink Wash (CIW)**

Step 1 – Use **DUAL STRIP** to remove ink (Plastisol & UV) and stencil simultaneously

Step 2 – Use **KIWOCLEAN Concentrated Ink Wash (CIW)** to remove ink stains



These two 1-gallon containers make up to 9 gallons of reclaiming and de-hazing solution

Save Time, Money and Reduce Your Impact on the Environment

Dual Strip is solvent-free. Both products are concentrated, which reduces packaging, shipping weight, transportation costs, and once diluted lowers CIW's VOC level and flammability rating.

DILUTION RECOMMENDATIONS:

DUAL STRIP

- 1 part DUAL STRIP to 1 part water for manual application using spray bottle
- 1 part DUAL STRIP to 5 parts water for use in dip tanks

KIWOCLEAN Concentrated Ink Wash (CIW)

- 1 part KIWOCLEAN CIW to 2 parts water for removing stains and degreasing

Both products available in quart, gallon, 5-gallon and 55-gallon sizes

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